Molecular Modelling of Supported Metal Catalysts: SiO₂-grafted [$\{\eta^3 - C_4H_7\}$ ₂Rh $\}$ ₂V₄O₁₂] and [{Rh(C₂Me₅}}₄V₆O₁₉] are Catalytically Active in the Selective Oxidation of Propene **to Acetone**

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SiO₂-grafted [{(η ³-C₄H₇)₂Rh}₂V₄O₁₂] and [{Rh(C₅Me₅)}₄V₆O₁₉], as molecular models of supported Rh catalysts characterized **by EXAFS,** FTIR and TPD studies, exhibit high catalytic activities for the selective oxidation of propene to acetone.

Organometallic oxide clusters such as $[{(\eta^3-C_4H_7)_2Rh}]_2-(V_4O_{12})$, cubane-type $[{(M(C_5Me_5))_4Mo_4O_{16}}]$ and $[{M(C_5Me_5)}_4V_6O_{19}]$ (M = Rh, Ir) are of interest as models of the infinite layer structures of $MoO₃$ and $V₂O₅$ crystals, which have been used as heterogeneous catalysts for the oxidation of organic compounds.1 They have multifunctional properties and synergistic effects on reactivity owing to the heterometallic centres. Furthermore, they are potential molecular models2 relevant to metal-supported catalysts whose catalytic activity and selectivity are affected by localized metal-support bonding. In this study, novel organometallic oxide clusters such as were used as molecular precursors for grafting organometallic oxide clusters onto a silica surface. These attached multicentred metal oxide clusters were well characterized by EXAFS (extended X-ray absorption fine structures), FTIR (Fourier transform infrared) and TPD (temperature-programmed desorption) studies, showing the 'vanadate tetramer and hexamer' oxide cluster frameworks capped by rhodium species, which remained grafted to the surface with silanol-Rh ligand interactions. We report here that the resulting $SiO₂$ -attached $Rh_2V_4O_{12}$ and $Rh_4V_6O_{19}$ clusters exhibit higher catalytic activities for the selective oxidation of propene to acetone. $[{M(C_5Me_5)}_4Mo_4O_{16}]$ and $[Bu^n_4N_2[\{(\eta^3-C_4H_7)_2Rh\}_2(V_4O_{12})]$ and $[\{Rh(C_5Me_5)\}_4V_6O_{19}]$

 $[Bu^n_4N]_2[\{(\eta^3-C_4H_7)_2Rh\}_2(V_4O_{12})]$ and $[\{Rh(C_5Me_5)\}_4$ - V_6O_{19}] were synthesized and purified by the literature methods, $3,4$ and were impregnated at 300 K onto SiO₂ (Aerosil 200, Japan Aerosil Co.; surface area 200 m² g⁻¹; dehydrated by evacuation at 573 K). SiO₂ was mixed with the CH₂Cl₂ solution of both cluster compounds, followed by removal of the solvent. The mass loading of the cluster in each sample was 15-20% (m/m) with respect to silica. The impregnated material (0.4 g) was mounted into the microreactor and treated by thermal activation *in vacuo* or by exposure to 13.3 kPa of O_2 at 353–413 K, resulting in SiO₂-grafted samples, denoted as $Rh_2V_4O_{12}/$ $SiO₂$ **1** and $Rh₄V₆O₁₉/SiO₂$ **2.**

The IR spectra (recorded on a Shimadzu FT-IR 8100M IR spectrometer wtih a resolution of 2 cm⁻¹) of $[Bu^n_4N]_2$ [{ $(n^3 C_4H_7$)₂Rh}₂(V₄O₁₂)] on silica gave bands at 3078 and 3056 cm⁻¹, characteristic of the stretching v(C-H) of $(\eta^3-C_4H_7)_2Rh$ groups capping the precursor cluster, which decreased gradually with increasing evacuation temperature up to 413 **K,** along with a considerable suppression of the 3765 cm^{-1} sharp band due to isolated silanol groups on the silica support. On the other hand, the IR bands at 2990, 2962, 2919 and 2875 cm⁻¹ due to vCH_3 / $CH₂$) of the counter-cation $[Buⁿ₄N]⁺$ remained unchanged below 450 K. Similarly, it was found by IR observation that the (C_5Me_5) ligand in $[\{Rh(C_5Me_5)\}_4V_6O_{19}]/SiO_2$ was partially eliminated by thermal evacuation at 423 K and under an O_2 atmosphere at 373 K.

TPD studies were performed using 0.2 g of the sample, *e.g.* C_4H_7)₂]/SiO₂ (acac = acetylacetone) which were charged in microreactor and heated by flowing He from 300 to 600 \bar{K} with a heating rate of $2 K min^{-1}$. Desorbed species were detected by gas chromatography using a TCD detector with VZ-7 column, coupled with mass spectroscopy (ANELVA Co, AQP-100). In $[Bu^n_4N]_2[\{(\eta^3-C_4H_7)_2Rh\}_2(V_4O_{12})]/SiO_2$ and $[Rh(acac)(\eta^3-$ the TPD spectra shown in Fig. 1, it was found that 2-methylpropene, derived from *ca.* 50% of the η ³-C₄H₇ ligands bound to $Rh_2V_4O_9$ and Rh(acac) moieties on the silica surface, was evolved at 350–413 K, and all completely desorbed below 450 K. Other species such as CH_4 , \hat{C}_3H_6 and but-2-enes were formed on $[Bu^n_4N]_2[{ (n^3-C_4H_7)_2Rh}_2(V_4O_{12})]/SiO_2$ (Fig. 1A) at temperatures $>$ 450 K. These products were associated with Hofmann degradation⁵ of the $[\bar{Bu}n_4N]^+$ counter-cation.

Rh and V-K-edge EXAFS spectra were measured in the transmission mode at BL-1OB or BL-7C of the Photon Factory in the National Laboratory for High Energy Physics. The spectra were analysed with a curve-fitting method using the program of EXAFS2 (Research Center for spectroscopy, The University of Tokyo) with theoretical parameters, as previously reported.6 The FT peaks of the Rh-C and Rh-0 contributions were obtained from the raw Rh-edge EXAFS data for $[Bu^n_4N]_2[\{\eta^3-C_4H_7\}_2Rh\}_2(V_4O_{12})]/SiO_2$ with a k^3 -weighting over the range 3.5 < k < 15 Å⁻¹. When the sample was evacuated at 4 13 **K,** the intensity of the Rh-C peak decreased *(R* $= 2.17$ Å, C.N. $= 3.2$) to 50% of that in the precursor sample $(R = 2.19 \text{ Å}, \text{C.N.} = 5.6)$, whereas the C.N. of the Rh–O $(R = 1.19 \text{ Å})$ 2.07 A) bonds increased relative to the precursor sample from 1.8 to 2.1, possibly owing to surface attachment of the capped

Fig. 1 TPD patterns of: A, $[Bu_n^aN]_2[{((\eta^3-C_4H_7)_2Rh)_2(V_4O_{12})}]$; and **B**, $[Rh(acac)(\eta^3-C_4H_7)_2]$ impregnated on SiO₂ gel. Yields are given of: (a) 2-methylpropene; (b) methane; (c) propane; (d) butane; (e) trans-but-2-ene; and (f) cis-but-2-ene.

 $(n^3-C_4H_7)_2$ Rh with silanol groups. Table 1 shows structural parameters for k^3 weighted V-K-edge EXAFS of Rh₂V₄O₁₂/ $\overline{SiO_2}$ 1 and $Rh_4V_6O_19/SiO_2$ 2 before and after the thermal activation *in vacuo* or in an 02 atmosphere of 13.3 kPa. When sample 1 was evacuated at 300-413 K, the intensity and shape of the FT peaks of V=O and V-0 remained unchanged, which agrees well with those of the precursor cluster, *i.e.* $[\bar{\text{Bu}}^n_4\text{N}]_2$ [{ $(\eta^3-\text{C}_4\text{H}_7)$ ₂Rh}₂(V₄O₁₂)] in the crystalline state. When **1** was evacuated at *5* 13 K, the resulting FT spectra were changed substantially, to resemble that of the conventional V_2O_5/SiO_2 which was prepared by calcination of ammonium vanadate on silica. The V-O-M contributions to the EXAFS oscillation of samples **1** and **2** were observed at 2.99 and 2.74 A, respectively. The V-0-M contributions decreased when the sample was evacuated above 413 K. Accordingly, the results of FTIR, EXAFS and TPD studies suggest that the chair-form vanadate tetramer and the hexamer clusters capped with $(\eta^3 C_4H_7$)₂Rh and Rh(C_5Me_5) groups were grafted with Rh end-on to silica surface, as depicted in Scheme 1; the vanadium oxide $(V_4O_{12}$ and $V_6O_{19})$ cluster frameworks remain basically unchanged, at least by thermal activation *in vacuo* or under 13.3 Wa *O2* below 413 K.

The oxidation of propene was carried out at $313-413$ K by using a closed circulating system equipped with a Pyrex glass reactor of volume 206 ml. A mixture of propene (13.3 kPa) and oxygen (13.3 kPa) was admitted onto the samples of **1** and **2.** Products consisting of acetone and $CO₂$ were quantitatively analysed (gas chromatography; Shimadzu GC-8A) using TCD with TCP 20%/Uniport R for oxygenates such as acetone and a Porapak Q column for propene, O_2 and CO_2 . It was interesting to find that although propene oxidation occurred negligibly on both Rh-capped vanadium oxide cluster compounds in the crystalline state, acetone was produced catalytically with higher selectivities (43-85 mol%) on **1** and 2 grafted onto a silica surface.

As shown in Table 2, 2 exhibited higher selectivities towards acetone than **1.** By contrast, the oxidation of propene to acetone over Rh(acac)(η^3 -C₄H₇)₂/SiO₂ gave poor selectivities and conversions with a higher activation energy of 73.7 kJ mol⁻¹. Nevertheless, a negligible amount of acetone was obtained in the reaction on $[V_{10}O_{28}]/SiO_2$ derived from the non-Rh capped vanadate dodecamer cluster and the conventional V_2O_5/SiO_2 under the similar reaction conditions. These results suggest that the coordinately unsaturated Rh sites capped with vanadium

Table 1 Structural parameters of V-K-edge EXAFS for [Bun4N]2[{ **(q3-C4H7)2Rh}2(V4012)]/Si02** and (Rh(C5Me5)}4V6019/Si02 before and after thermal activation *in vacuo* and under an O₂ atmosphere

Sample	FT peaks			C.N. ^a $R^b/\text{\AA}$ R factor (%)
$[Bu^n_4N]_2$ [{(n ³ -C ₄ H ₇) ₂ Rh} ₂ (V ₄ O ₁₂)]/BN ^c	$V=O$	1.0	1.65	13.3
$[Bu^n_4N]_2[\{(n^3-C_4H_7)_2Rh\}_2(V_4O_{12})]/SiO_2$ impregnation	$V - O$	3.0	1.82	
	$V=0$	1.2	1.65	7.2
	$V - O$	3.7	1.84	
After evac. $(413 K)$	$V=O$	1.0	1.64	6.5
	$V - O$	3.1	1.84	
Exposure to O_2 (413 K)	$V = 0$	1.0	1.64	15.4
	$V - O$	3.3	1.83	
Exposure to O_2 (523 K)	$V = 0$	0.7	1.65	10.4
	$V-O$	2.1	1.84	
	$V=O$	1.0	1.62	
${Rh(C_5Me_5)}_4V_6O_{19}/BN$	$V - O_h$	4.0	1.88	5.2
	$V - Oc$	1.0	2.31	
	$V=O$	1.0	1.60	
$\{Rh(C_5Me_5)\}\,4V_6O_{19}/SiO_2$ impregnation	$V - O_h$	4.0	1.88	8.3
	$V - O_c$	2.2	2.29	
	$V=O$	1.2	1.62	
After evac. (373 K)	$V - O_h$	3.5	1.86	4.2
	$V - O_c$	1.2	2.28	

^{*a*} C.N. = normalized coordination number. *b* R = interatomic distance. *c* BN = boron nitride.

Scheme 1

Table 2 Catalytic performance of SiO₂-grafted vanadate tetramer and hexamer capped with Rh and other impregnated materials ($p_{C_3H_6} = p_{O_2} = 13.3$ kPa; reaction temp. $=$ 343 K)

a Selectivity to acetone. *b* Activation energy for acetone and CO₂ formation.

oxide cluster frameworks are associated with the selective catalysis for propene oxidation to give acetone. The catalytic activity and selectivity for acetone formation decreased substantially on exceeding the activation temperature of 513 K, possibly owing to the degradation of Rh capped vanadate clusters. For the Arrhenius plots in propene oxidation on $Rh_2V_4O_{12}/SiO_2$, the activation energies obtained were 46.8 kJ mol⁻¹ for acetone production and 35.5 kJ mol⁻¹ for CO_2 production, respectively.

As recently reported by Mimoun *et al.*,7,8 allyl-Rh complexes catalysed the selective oxidation of alk-1-enes to 2-ketones in solution, the activity of which was strongly retarded by water. Actually, we found that acetone formation from propene oxidation on **1** and **2** was not affected or suppressed by the addition of water. These results indicate that this reaction was not a Wacker-type reaction likely to occur on the conventional binary acidic Mo-Co oxides and redox-cycle catalysed by $CuCl₂-PdCl₂$ in solution. By contrast, acetone is formed by a direct reaction between propene and O_2 through a peroxy intermediate. Schwartz *et al.*⁹ also recently reported that acetone was formed with higher selectivities on the surfacegrafted Rh species derived from $Rh(\pi$ -allyl)₃ impregnated on Al_2O_3 . In summary, we suggest that a coordinatively unsaturated Rh site accommodated by V_4O_{12} and V_6O_{19} cluster frameworks as supporting oxide modelling is responsible for the selective oxidation of propene to acetone, possibly owing to a bifunctional role¹⁰ played by Rh and vanadate cluster moieties.

Received, 13th March 1995; Corn. 5101545F

Footnote

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